

Crystallizing the future of oxide materials

January 25 2012



University of Arkansas physicist Jak Chakhalian.

(PhysOrg.com) -- A University of Arkansas physicist and his colleagues have examined the challenges facing scientists building the next generation of materials and innovative electronic devices and identified opportunities for taking the rational material design in new directions.

Jak Chakhalian of the University of Arkansas, A.J. Millis of Columbia University and J. Rondinelli of Drexel University present their ideas in the current issue of *Nature*.

"Where you see issues, there are opportunities," Chakhalian said.

The researchers focus on complex oxide interfaces with strongly correlated electrons, which are artificially created structures involving materials called transition metal oxides. Oxide interfaces have the



potential to revolutionize materials and devices based on them the way that semiconductors once did, but researchers find themselves hampered by several obstacles.

First, no one has developed a comprehensive theory of why oxide interfaces behave as they do, which means that scientists cannot predict or often even explain the materials' properties. Second, scientists face challenges in synthesizing these complex materials with atomic precision. Synthesizing involves taking several chemical elements balanced very precisely and combining them into intricate geometrical arrangements. On top of this, to create interfaces, scientists must grow these very dissimilar materials together.

While these challenges may seem intimidating, Chakhalian and his colleagues see two opportunities. The first is to grow materials in unusual directions. Chakhalian has already demonstrated that an oxide interface grown along the diagonal of a cube will crystalize into triangular and hexagonal atomic patterns, while the same material grown on a conventional "horizontal" surface will have a common cubic pattern.

"When grown along the diagonal, from the mechanical, electronic and magnetic properties point of view it becomes a new, exotic material," he said. By forcing materials to grow in directions that they would usually resist in nature, Chakhalian suggests a way to find these novel exotic materials.

The second opportunity involves creating interfaces between oxide materials and materials where oxygen is replaced by another element, which leads to entirely new <u>materials</u> with novel electronic properties. For instance, nickel oxide is an insulator but nickel sulfide is metallic. By alternating an oxide-based layer with a non-oxide based layer, scientists propose creating interfaces with important properties for,



among other things, energy savings and water purification.

"If you want to talk about the next nanoelectronics revolution or real solutions to the energy problem, these are some of the groundbreaking directions we propose to take," Chakhalian said.

Provided by University of Arkansas

Citation: Crystallizing the future of oxide materials (2012, January 25) retrieved 7 May 2024 from <u>https://phys.org/news/2012-01-crystallizing-future-oxide-materials.html</u>

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